

APPLICATION DATA SHEET

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Application Information

Application Type:: regular
Subject Matter:: utility
Title:: POSITIVE PHOTORESIST COMPOSITION AND
METHOD OF FORMING RESIST PATTERN
Attorney Docket Number:: SHIGA7.036APC

Inventor Information

Applicant Authority Type:: inventor
Primary Citizenship Country:: Japan
Status:: full capacity
Given Name:: Yasuo
Family Name:: Masuda
Street:: c/o TOKYO OHKA KOGYO, CO., LTD., 150,
Nakamaruko, Nakahara-ku, Kawasaki-shi
City:: Kanagawa-ken
Country:: Japan

Inventor Information

Applicant Authority Type:: inventor
Primary Citizenship Country:: Japan
Status:: full capacity
Given Name:: Toshiki
Family Name:: Okui
Street:: c/o TOKYO OHKA KOGYO, CO., LTD., 150,
Nakamaruko, Nakahara-ku, Kawasaki-shi
City:: Kanagawa-ken

Country:: Japan

Correspondence Information

Correspondence Customer Number:: 20,995

Phone Number:: (949) 760-0404

Fax Number:: (949) 760-9502

Representative Information

Representative Customer Number:: 20,995

Domestic Priority Information

Application::	Continuity Type::	Parent Application::	Parent Filing Date::
This Application	National Phase	PCT/JP2004/010270	July 13, 2004

Foreign Priority Information

Country::	Application Number::	Filing Date::	Priority Claimed::
Japan	2003-197873	July 16, 2003	Yes
Japan	2003-197874	July 16, 2003	Yes

Assignment Information

Assignee Name:: TOKYO OHKA KOGYO, CO., LTD.

Street:: 150, Nakamaruko, Nakahara-ku, Kawasaki-shi

City:: Kanagawa-ken

Country:: Japan